



GEANT4
A SIMULATION TOOLKIT
Version 11.2



Event Biasing and Fast Simulation

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11th International Geant4 Tutorial in Korea,

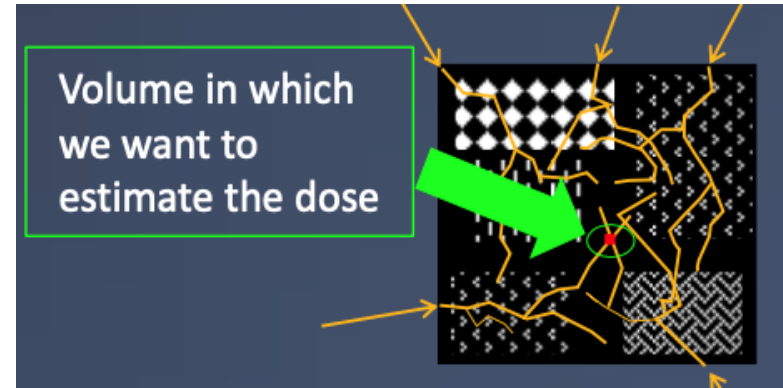
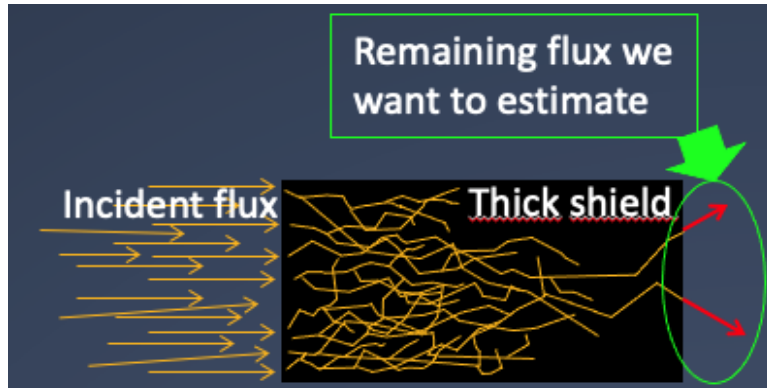
Aug 19-23, 2024 @YonSei Univ., Wonju

Contents

- Event Biasing
 - Overview of Event Biasing
 - Early Provided Biasing Options
- Fast Simulation
 - Interfaces
 - Examples

Rare Events

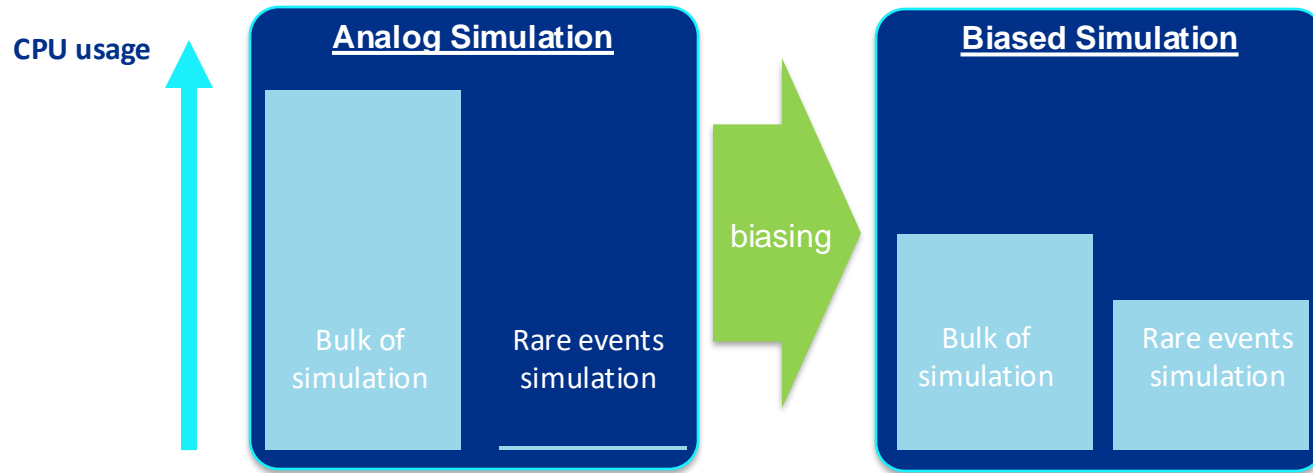
- There are simulation problems in which what we are interested in is “rare” because of the physics or the setup (or both)
- Examples of such problems
 - Estimating the efficiency of a shield or obtaining responses of a very thin detector
 - Estimating the dose in a very small part of a big setup (e.g., an electronic chip inside a satellite)



- An analog simulation is inefficient in addressing these problems → Event biasing technique

What is “Event biasing” ?

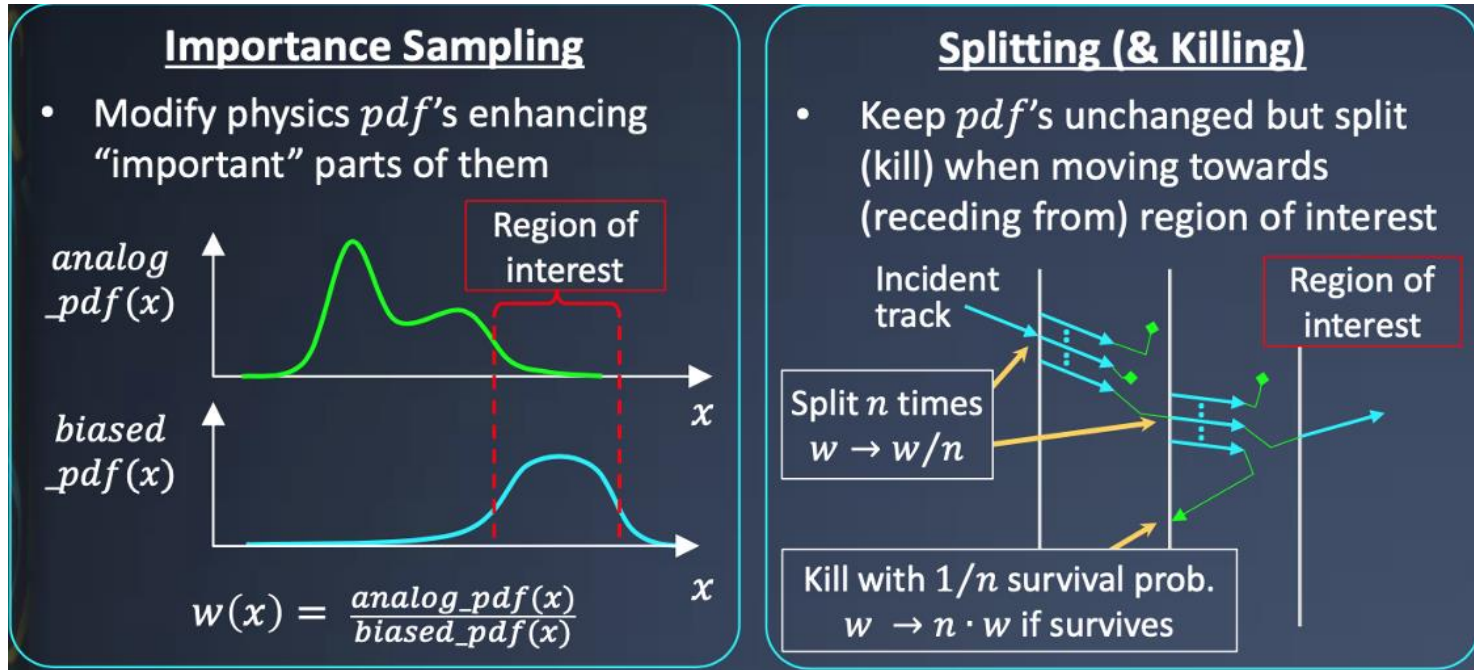
- “Event biasing” (or “biasing” or “variance reduction”) is a set of techniques to simulate rare events efficiently
 - It focuses/transfers the CPU power usage on what we want to tally



- It can provide LARGE CPU improvements (several orders of magnitude depending on the problem!)
- “Biasing” stands for “biased simulation”: “Biased” because rare events are enhanced compared to the analog simulation.

Main Principle

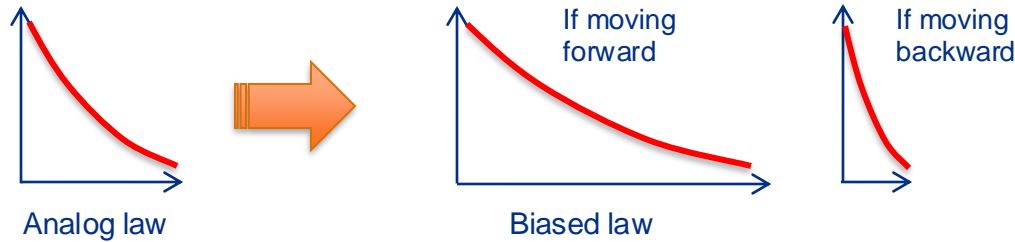
- There is a large variety of techniques, but there are essentially two underneath classes



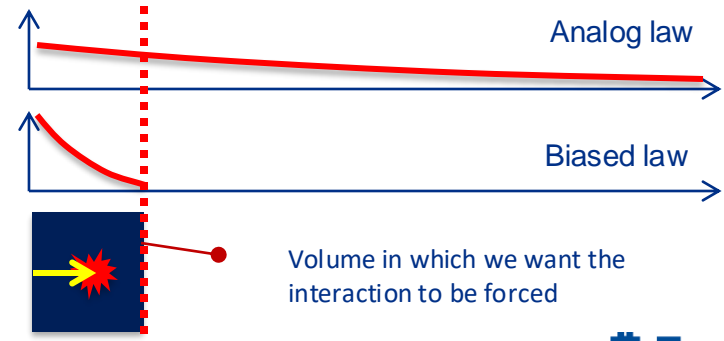
- Enhancement of rare events is tracked with statistical weights (w_i) which are used to de-bias and go back to analog quantities: e.g., $E_{\text{deposit}} = \sum_{i=\text{track}} w_i \times E_{\text{deposit}}^i$

Example of Importance Sampling Techniques

- Cross section biasing: the “exponential transform” technique
 - The exponential law is replaced by another law to enhance (or suppress) cross section (often with direction dependent). Available for hadron inelastic, electron and positron nuclear processes.

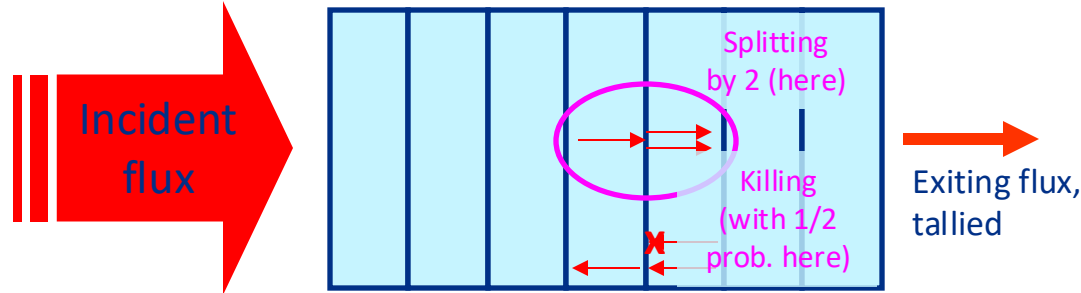


- Forcing the interaction in a thin volume:
 - The usual/analog exponential law is replaced by a truncated exponential law that does not extend beyond the volume limit



Example of Splitting

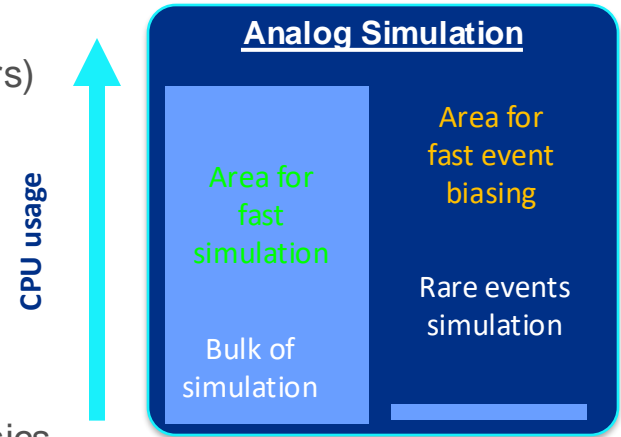
- A classical application of splitting is the “shield” simulation problem



- Particles moving toward exit are cloned biasing the physical absorption in the shield material
- When cloning happens, clones receive a weight of the initial track
- Splitting comes together with killing/Russian Roulette
 - For particles going opposite direction than the one we want
 - In above example, particles moving backward are killed with a probability $\frac{1}{2}$ and, if it survives, its weight is multiplied by 2.
 - “Too numerous” particles are killed (population control). It is used for example in CMS, for slow neutrons

Biasing vs. Other Acceleration Techniques?

- Other acceleration techniques exist:
 - Fast simulation: use approximate but faster model (e.g: EM showers)
 - Accelerates the bulk of the simulation
 - Deterministic computation (medical, space) (not in Geant4)
- Strength of biasing:
 - The physics at play in biasing is same with the detailed simulation
 - Biasing is “simply” another way to process the full detailed physics
 - So, results obtained with biasing are statistically the same than the ones obtained with a large/huge processing of standard simulation
- Difficulties with biasing:
 - Only “rare events” problems can be treated this way (by nature)
 - Ensuring a proper convergence can be difficult - issue of random appearance of large weights



Early Provided Biasing Options

Options In Hadronic (1)

- Cross-section Biasing:
 - Possibility to enhance a (low) cross-section
 - This an “importance sampling” approach
 - Available for photon inelastic, electron & positron nuclear processes

```
// Initialize a reaction model
G4ElectroNuclearReaction* electroReaction = new G4ElectroNuclearReaction();

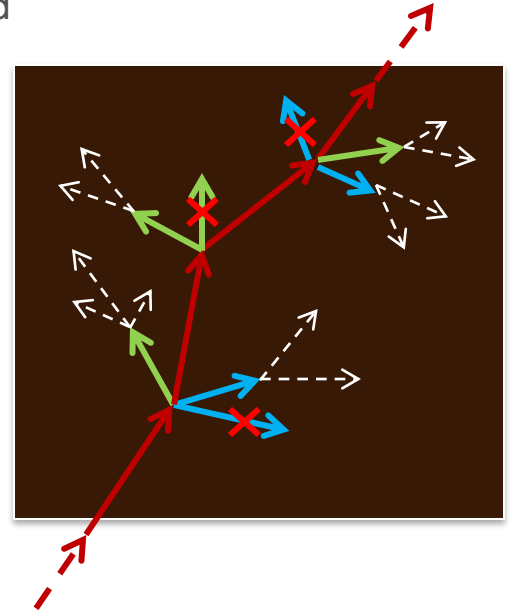
// Create an associated process and register the model
G4ElectronNuclearProcess electronNuclearProcess;
electronNuclearProcess.RegisterMe(electroReaction);

// Apply biasing
electronNuclearProcess.BiasCrossSectionByFactor(100);

// Register the process
procManager->AddDiscreteProcess(&electronNuclearProcess);
```

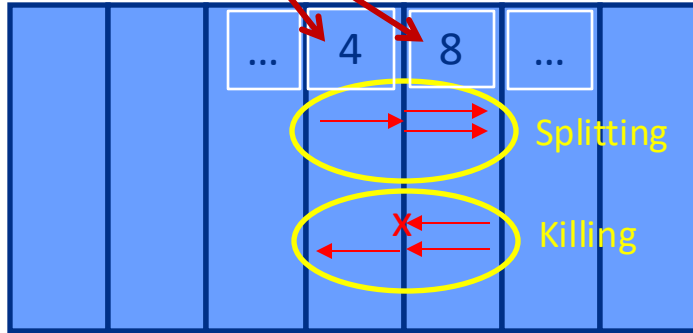
Options In Hadronic (2)

- Leading particle biasing:
 - A technique used for estimating the penetration of particles in a shield
 - Instead of simulating the full shower, at each interaction, only keep:
 - The most energetic particle
 - Randomly one particle of each species
 - This is a killing-based biasing
- Radioactive decay
 - Enhance a particular decay within a given time window
 - Sample all decay modes with equal probabilities
 - Split parent nuclide in a user defined number of copies, letting the decay go
 - Enhance emission in a particular direction



Geometry based importance biasing

- Attach “importance” to cells in geometry: change of probability density functions of interaction laws



- Applies splitting if the track moves forward
 - with splitting factor $8/4 = 2$, if track goes from « 4 » to « 8 » (e.g., here)
 - each copy having a weight = $\frac{1}{2}$ of the incoming track
- Applies killing if the track moves the other way
 - it is killed with a probability $\frac{1}{2}$
 - If particle survives, its weight is multiplied by 2 (e.g., here)

Geometry-based Importance Biasing

- Geometry cells, meant to carry importance values, are created and associated to physical volumes in the detector construction:

```
// Create an "importance store"  
G4IStore *istore = G4IStore::GetInstance();  
  
// Assign an importance value to (all) physical volumes  
istore->AddImportanceGeometryCell(importanceValue, physicalVolume);
```

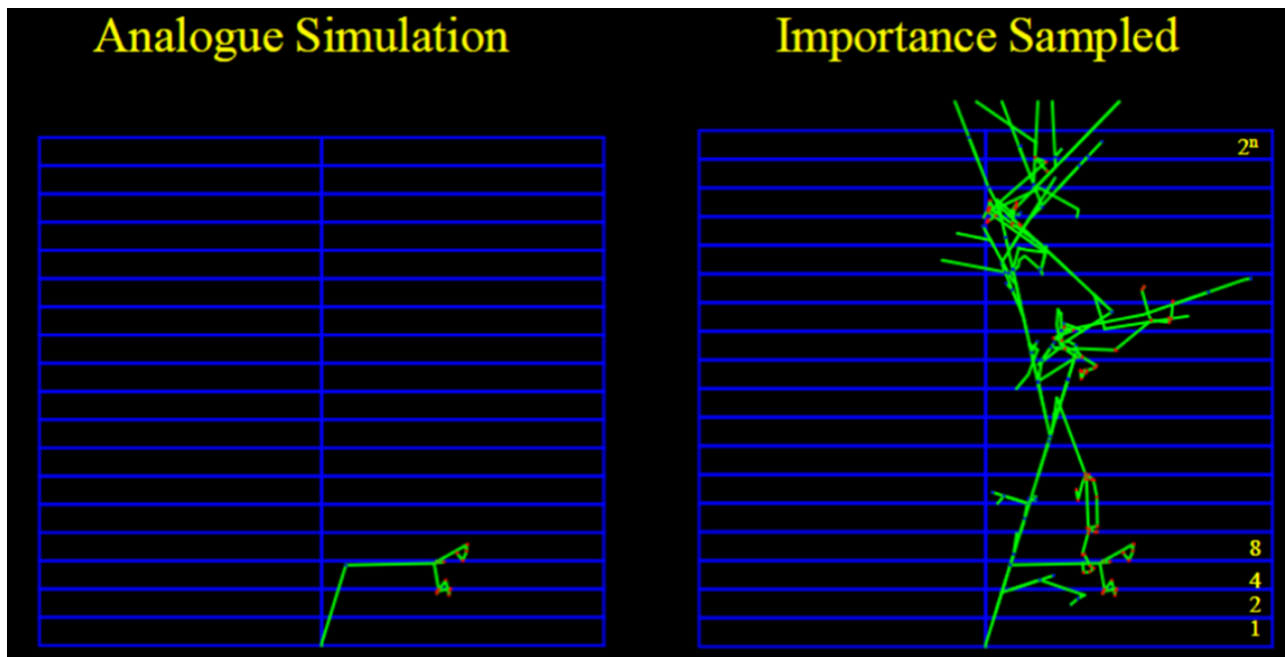
- The actual splitting and killing are handled by dedicated processes and biasing may be applied to some particle type only: e.g., neutron

```
// Apply to neutrons  
G4GeometrySampler geometrySampler(worldVolume, "neutron");  
  
// Register to the modular physics list  
G4VModularPhysicsList* physicsList = new FTFP_BERT;  
physicsList->RegisterPhysics(new G4ImportanceBiasing(&geometrySampler));
```

- More details can be found in examples/extended/biasing: B01, B02, B03

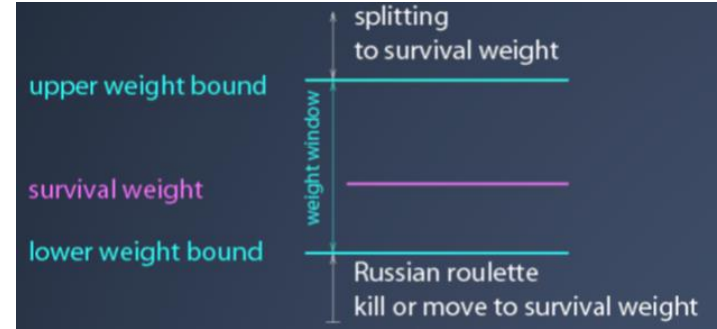
Example B01

- Geometry-based importance biasing for 10 MeV neutrons in a thick concrete cylinder: see [examples/extended/biasing/B01](#)
 - Assign importance values with a power of 2



Weight Window Technique

- This is a « splitting & killing » technique, to avoid having
 - Too high weight tracks at some point
 - As this makes the convergence of the estimated quantities difficult
 - Tracks with weight above some value are splitted
 - Too low weight tracks
 - As these are essentially a waste of time
 - Tracks below some value are “Russian roulette” - killed



- As with importance, this is configured per cell
 - And can be configured per energy
- See: [geant4/examples/extended/biasing/B01](https://geant4.org/examples/extended/biasing/B01)

User Defined Biasing

- G4WrapperProcess can be used to implement user defined event biasing
- G4WrapperProcess, which is a process itself, wraps an existing process
- All function calls forwarded to wrapped process
- Needed steps:
 - Create derived class inheriting from G4WrapperProcess
 - Override only the methods to be modified, e.g., PostStepDoIt()
 - Register this class in place of the original
 - Finally, register the original (wrapped) process with user class

Example of Bremsstrahlung Splitting

- Splitting is a technique used for example in medical applications:
 - Radio-therapy with photon beam generated by bremsstrahlung
 - Interest is in photons, not in the electron → enhance photon production
 - The bremsstrahlung process is repeated N times, All bremsstrahlung photons are given a weight 1/N
 - The electron continues with one of the state among N ones generated

```

G4VParticleChange* MyWrappedProc::PostStepDoIt(const G4Track& track, const G4Step& step)
{
    G4double weight = track.GetWeight()/fNSplit;

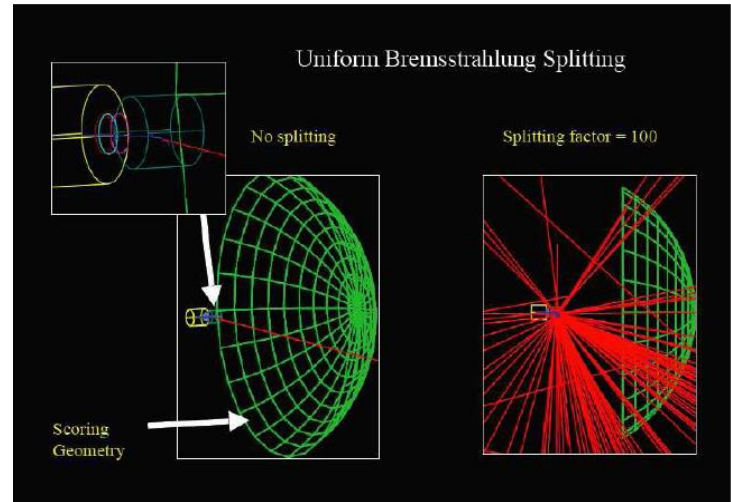
    // Secondary store
    std::vector<G4Track*> secondaries(fNSplit);

    // Loop over the wrapped PSDI method to generate multiple secondaries
    for (G4int i = 0 ; i < fNSplit ; i++)
    {
        particleChange = pRegProcess->PostStepDoIt(track, step);
        assert (0 != particleChange);

        // Save the secondaries generated on this cycle
        for (G4int j=0; j<particleChange->GetNumberOfSecondaries(); j++)
        {
            secondaries.push_back (new G4Track(*(particleChange->GetSecondary(j))));
        }
    }

    return particleChange;
}

```



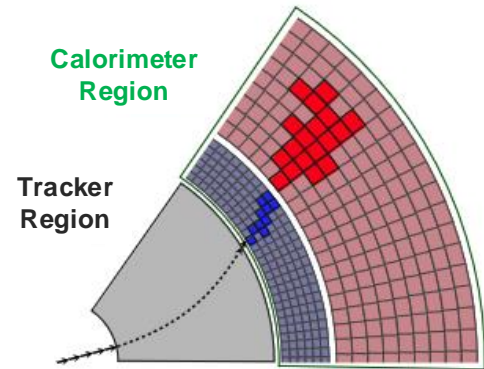
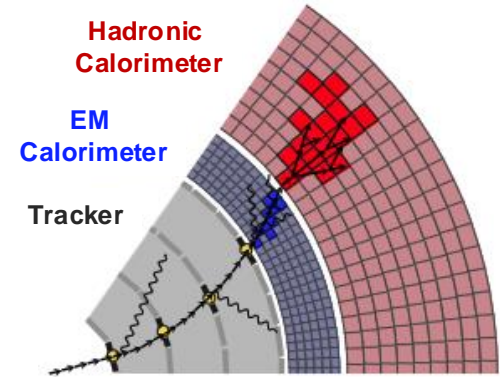
- geant4/examples/extended/biasing
 - GB01: Individual process cross-section biasing for neutral particles
 - GB02: Force collision à la MCNP for neutral particles (as MCNP)
 - GB03: Geometry importance + further options
 - Scheme augmented compared to classical geometry importance
 - GB04: Re-implementation of a classical Bremsstrahlung splitting
 - GB05: Illustrates a "splitting by cross-section"
 - GB06: Parallel geometries with generic biasing
 - GB07: Implement a "particle leading" biasing scheme
- See other topics on "Event Biasing" by M. Verderi at <https://indico.cern.ch/event/1172490/>
 - Reverse Monte Carlo
 - Generic biasing scheme

Fast Simulation

- Geant4 supports a fast simulation interface for a parameterized simulation
 - Quality (approximation) vs. Computing performance (faster than full simulation)
 - Replace Geant4 processes with external or user simulation codes
 - Allow a Geant4 process to be modified during simulation execution - very useful in certain cases
- User cases interfacing with
 - Parameterized physics (charge deposition in tracking layers, energy deposition from particle showers)
 - Fast simulation for optical photon propagation through optical fibers
 - External codes, crystal channeling as an example
 - Machine learning inference
 - Offloading a special task to other devices

How does the interface work?

- G4FastSimulationManager
 - Define G4Envelope (G4Region)
 - Add a model inherited from G4VFastSimulationModel
- G4VFastSimulationModel (pure virtual)
 - IsApplicable (particle definition)
 - ModelTrigger (dynamic conditions)
 - Dolt (model actions)
 - Flush (post clearance)
- G4FastSimHitMaker
 - make (sensitive detector)



Create Your Own Fast Simulation Model

- A concrete example for parameterization, offloading, inference, etc.

```
MyFastSimModel::MyFastSimModel(const G4String &name, G4Region *envelop)
: G4VFastSimulationModel(name, envelope)
{
    // Action of my model (parameterization, offloading, inference, etc)
    fAction = std::make_shared<MyFastSimAction>();
}

G4bool MyFastSimModel::IsApplicable(const G4ParticleDefinition &particle)
{
    // List of applicable particles
    return (&particle == G4Electron::ElectronDefinition());
}

G4bool MyFastSimModel::ModelTrigger(const G4FastTrack &track)
{
    // Minimum energy cutoff to parameterize
    return (track.GetPrimaryTrack()->GetKineticEnergy() < GeV) ? false : true;
}

void MyFastSimModel::DoIt(const G4FastTrack &track, G4FastStep &step)
{
    // Kill the parameterised particle
    step.KillPrimaryTrack();

    // Execute the action of MyFastSimAction class
    fAction->execute(track);

    // Make sensitive hits with the list of hits from the action
    this->makeHits(track);
}
```

Inherited from G4VFastSimulationModel

Applicable particles

Conditions to trigger this model

Actions of this model

Create sensitive hits

EM Cascade and EM Shower (Gflash)

- Geant4 supports a fast simulation interface for EM shower simulation

- e-γ cascade EM Parameterization (Gflash)

- *G4VFastSimulationModel*

- Longitudinal energy profile

- Gamma distribution: peak at $(\alpha-1)/\beta$

$$f(x; \alpha, \beta) = \frac{x^{\alpha-1} e^{-\beta x} \beta^\alpha}{\Gamma(\alpha)}$$

- α and β are correlated with fluctuations

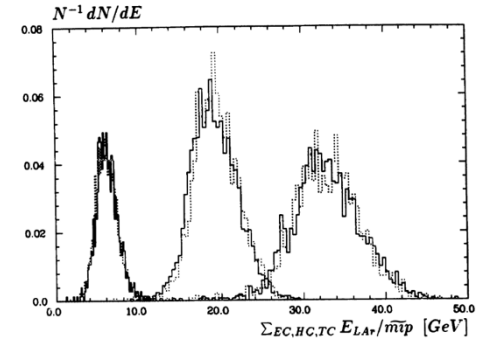
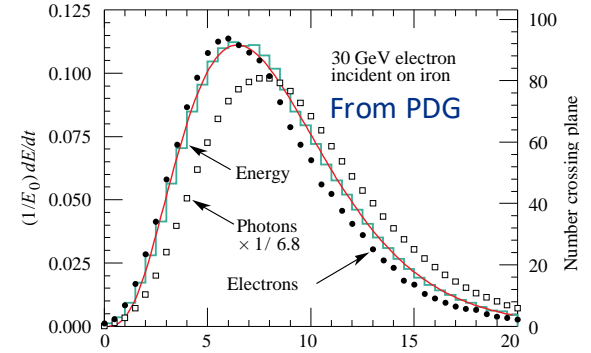
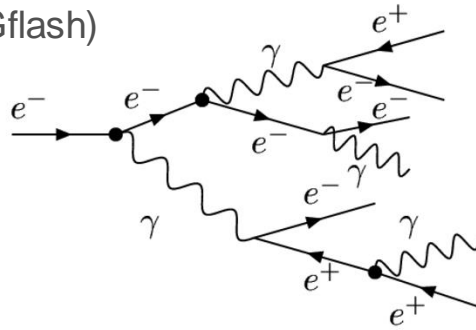
- Lateral profile

- Core (R_C) and tail (R_T) components of the radial distribution

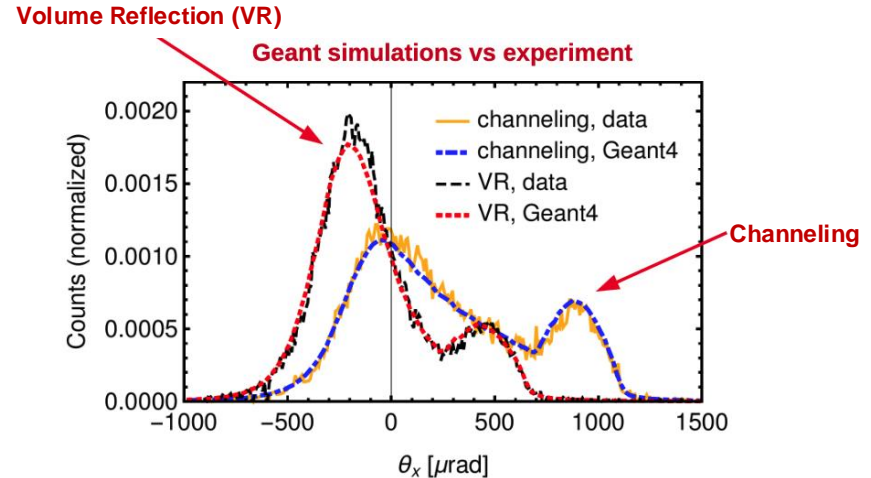
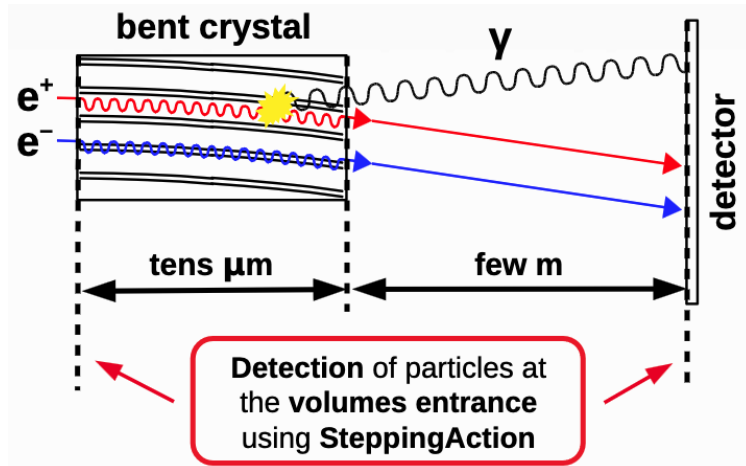
$$f(r) = p \frac{2rR_C^2}{(r^2 + R_C^2)^2} + (1-p) \frac{2rR_T^2}{(r^2 + R_T^2)^2}$$

- Energy deposition with a spot energy: $dE_{dep}(\vec{r}) = \frac{E_{dep}}{2\pi} f(x) dx f(r) dr$

$$\frac{\sigma_a}{E_{dep}} = \frac{a}{\sqrt{E_{inc}}}, \quad E_{spot} = a^2$$



- Can use fast simulation to speed up transport of e^\pm on ultra-short crystal at Mainz Mikrotron
 - 855MeV electron experiments at MAMI, A. Mazzolari et al. PRL. 112, 135503 (2014), A. Sytov et al. Eur. Phys. J. C 77, 901 (2017), JKPS 83, 132–139 (2023), see Alexei talk's at <https://hep0.kisti.re.kr/event/6/>
 - [G4ChannelingFastSimModel](#) (source/parameterisations/channeling)

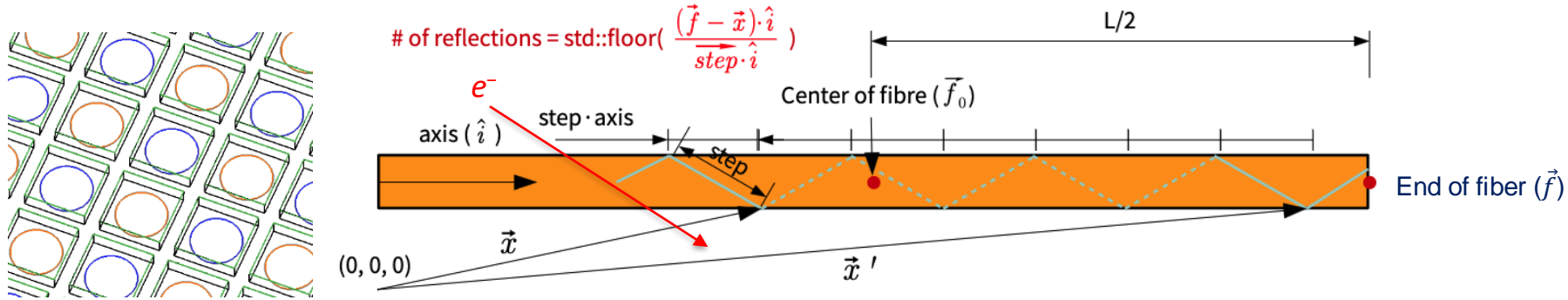


- Multithreaded version of this has run on NURION@KISTI supercomputer

Fast Optical Photon Transportation in Dual Readout Calorimeter

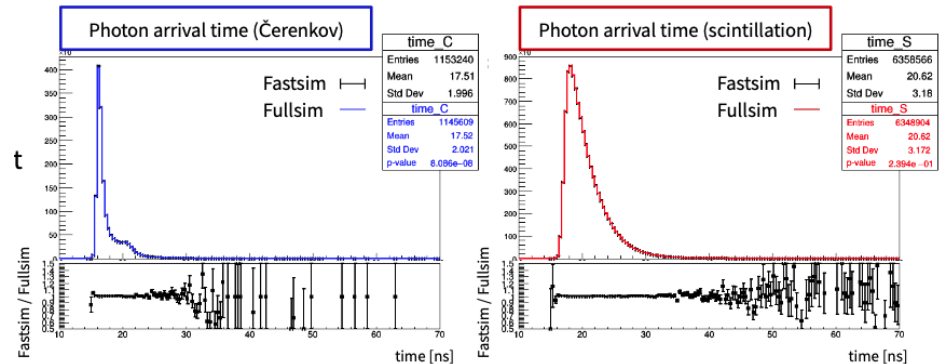
- Not all intermediate transportation steps are needed for the simulation (Sanghyun Ko, SNU)

<https://indico.cern.ch/event/915715/>



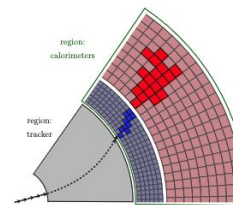
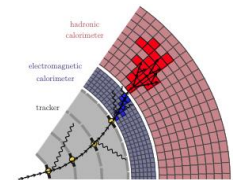
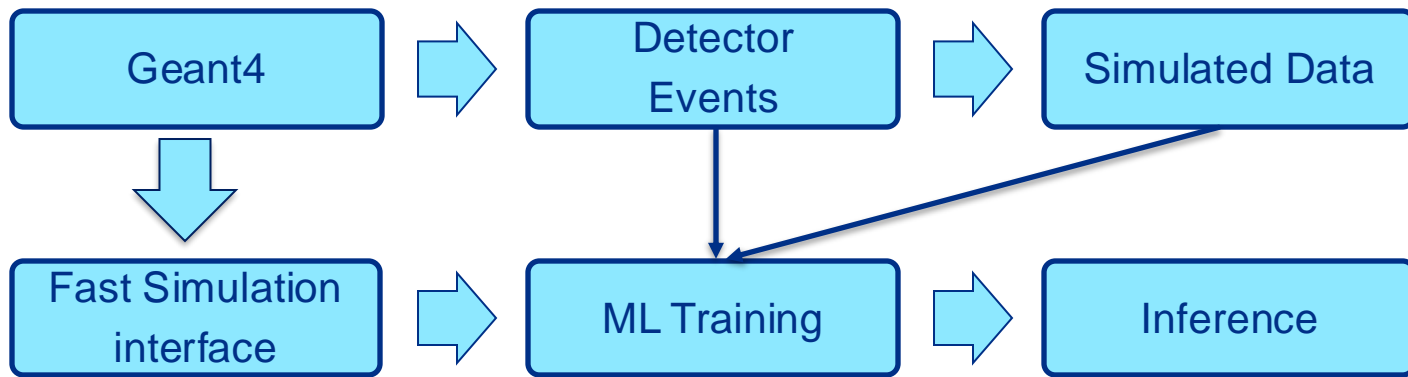
- CPU time: 1000 of 20 GeV e^- events

- Full simulation: 4.62 ± 1.17 min
- Fast simulation: 304 ± 88 min
- Gain: ~70 times

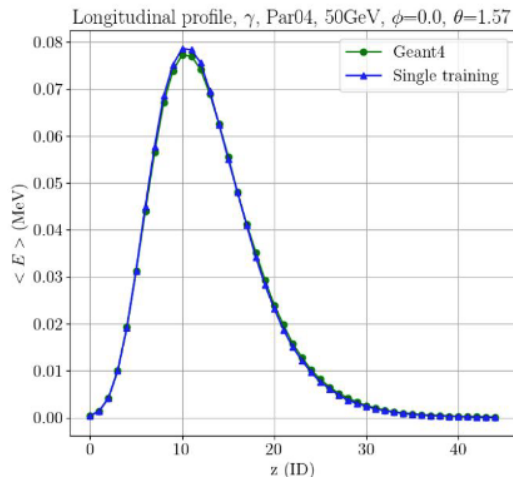
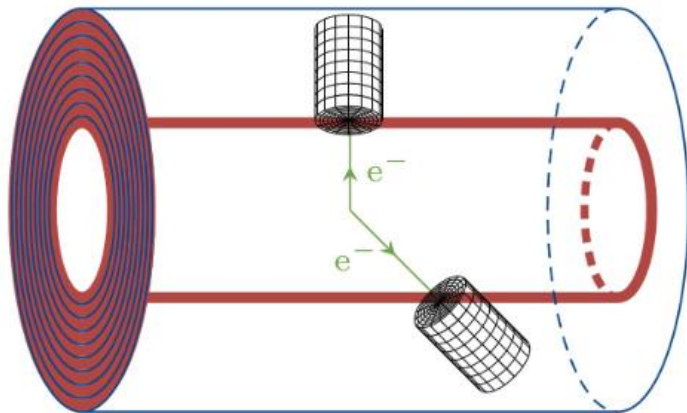


Machine Learning

- Various Machine Learning for simulation
 - CNN (image)
 - VAE (self-learning)
 - GAN (fake vs. real)
- The Geant4 fast simulation model provides a self-contained ML interface for training and inference: each experiment requires a specific ML designing model and target



- Calo Challenge



- Par04 Fast simulation model can upload neural network parameters for inference using
 - Lightweight Trained Neural Network or
 - Open Neural Network Exchange (ONNX) libraries
 - Torch

- examples/extended/parameterisations/
- Par01
 - Par01EMShowerModel (crude e^- , e^+ , γ shower parameterization)
 - Par01PionShowerModel (crude π^+ , π^- shower model in ghost volume)
 - Par01PiModel (shows how a parameterization can create secondaries)
- Par02
 - Par02FastSimModelEMCal.cc (e^- , e^+ , γ in EM calorimeter using energy smearing)
 - Par02FastSimModelHCal (hadrons in hadronic calorimeter using energy smearing)
 - Par02FastSimModelTracker
- Par03EMShowerModel (creates and store multiple energy deposits)
- Par04MLFastSimModel (machine-learning aided fast simulation of electromagnetic showers)
- /gflash GFlashShowerModel (use of the GFLASH EM parameterization library)

- Event biasing techniques can provide very large acceleration factors in problems in which we must tally rare events. Geant4 supports a variety of biasing options
 - Leading particle, cross-section (had), radioactive decay, splitting with importance in geometry, weight window, user biasing with G4WrapperProcess, and bremsstrahlung splitting
 - they delicate to handle, but sometimes unmissable when dealing with rare event problems
- Geant4 provides “Fast Simulation Interface” which can replace standard Geant4 processes during code execution to speed up simulations or implement external codes
 - It is activated only in a particular G4Region under certain conditions and for certain particles
 - Many applications for fast simulation
 - Electromagnetic shower in homogeneous and/or sampling calorimeters
 - Machine learning inference
 - Offloading specialized tasks to accelerators or heterogenous hardware (GPUs, ...)